

[54] FACIAL MASK

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[**] Term: 14 Years

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[52] U.S. Cl. D2/234; D2/239

[58] Field of Search D2/230, 234, 233, 239, D2/253; 2/206; 128/132 R, 136, 139; D24/49

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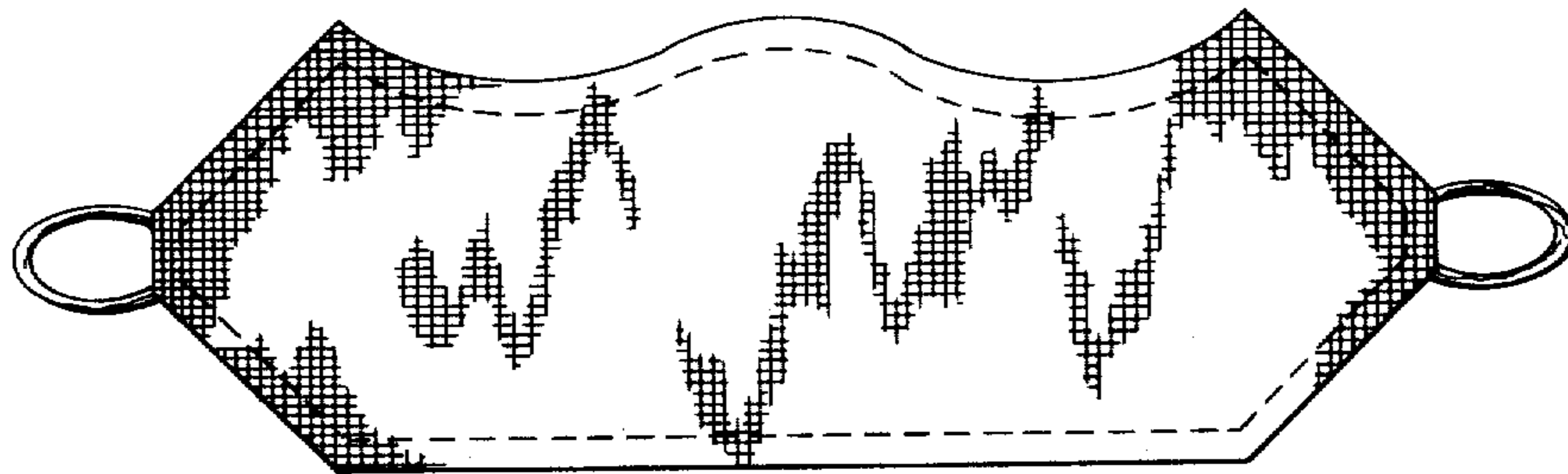
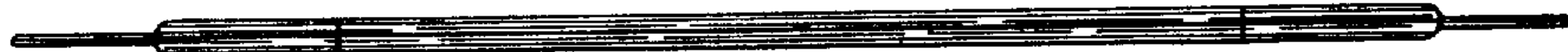
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[57] CLAIM

The ornamental design for a facial mask, as shown and described.

DESCRIPTION

FIG. 1 is a front elevational view of a facial mask showing my new design;
FIG. 2 is a rear elevational view thereof;
FIG. 3 is a top plan view thereof;
FIG. 4 is a bottom plan view thereof;
FIG. 5 is a left side elevational view thereof;
FIG. 6 is a right side elevational view thereof; and
FIG. 7 is a perspective view thereof, the broken line showing of a human profile is for illustrative purposes only.



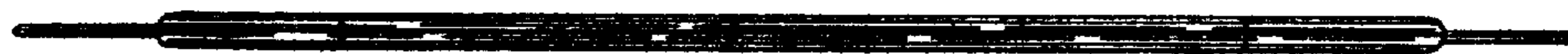


FIG. 3

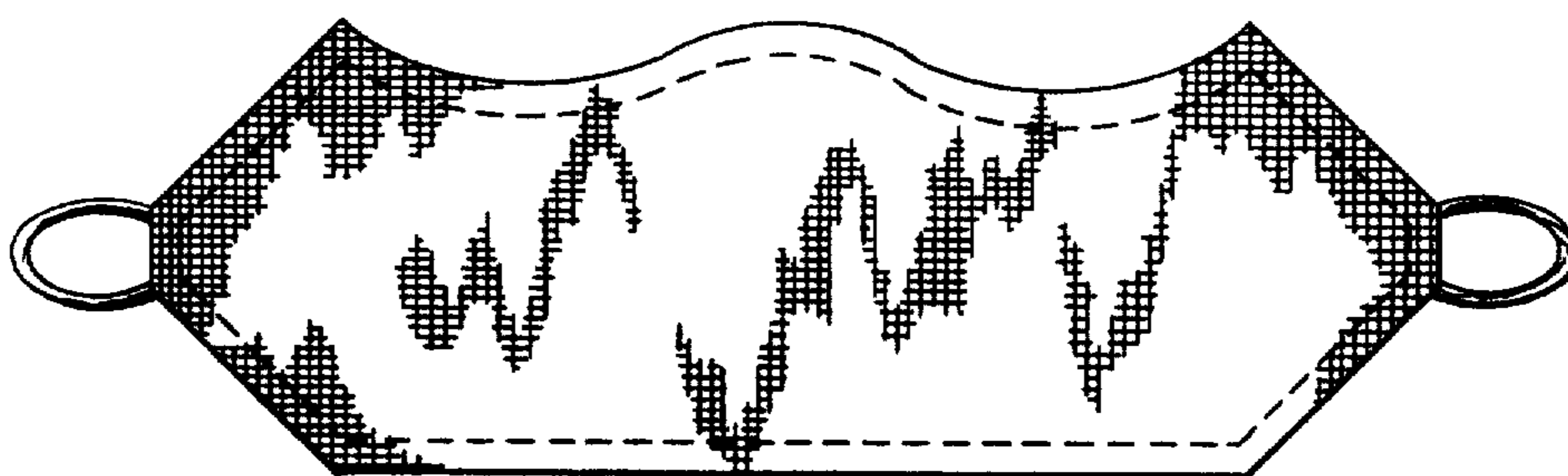


FIG. 5

FIG. 1

FIG. 6



FIG. 4

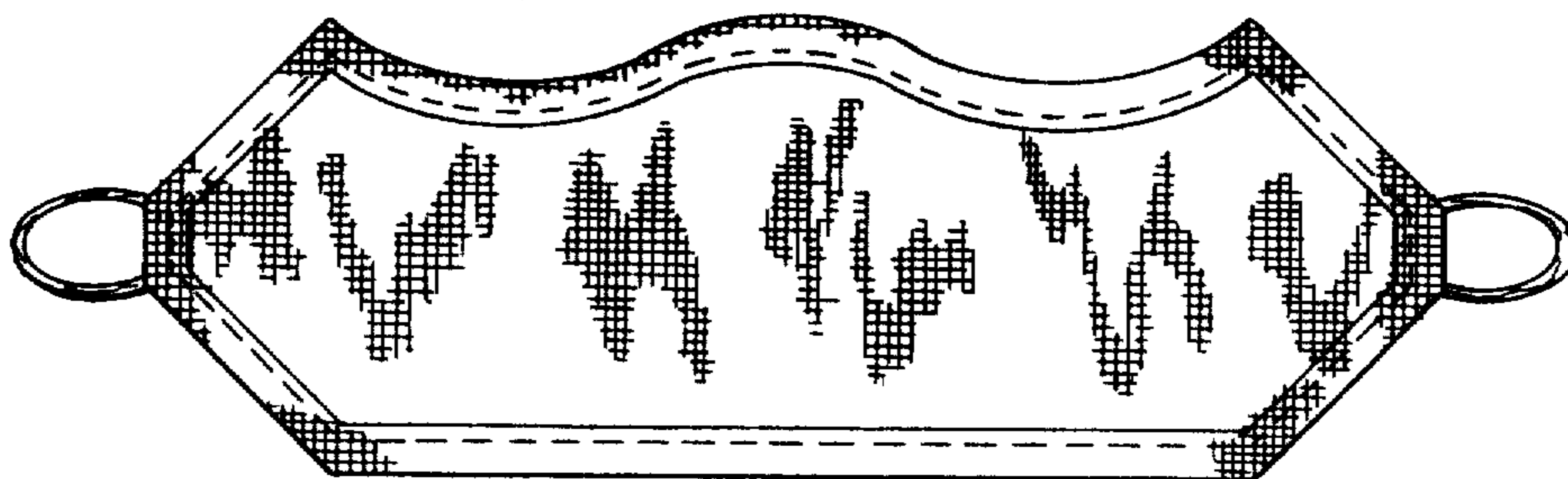


FIG. 2



FIG. 7